A nom alous spin-orbit e ects in a strained InG aA s/InP quantum

well structure

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Abstract

There currently is a large e ort to explore spin-orbit e ects in sem iconductor structures with the ultim ate goal of manipulating electron spins with gates. A search for materials with large spin-orbit coupling is therefore important. We report results of a study of spin-orbit e ects in a strained InG aAs/InP quantum well. The spin-orbit relaxation time, determined from the weak antilocalization e ect, was found to depend non-monotonically on gate voltage. The spin orbit scattering rate had a maximum value of $5 ext{ } 10^{10} \text{ s}^{\,1}$ at an electron density of $n=3 ext{ } 10^{15} \text{ m}^{\,2}$. The scattering rate decreased from this for both increasing and decreasing densities. The smallest measured value was approximately $10^9 \text{ s}^{\,1}$ at an electron concentration of $n=6 ext{ } 10^{15} \text{ m}^{\,2}$. This behavior could not be explained by either the Rashba or the bulk D resselhaus mechanisms but is attributed to asymmetry or strain electron explained well interfaces.

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A. Introduction

In A_3B_5 sem iconductors containing heavy metal elements, such as indium, spin-orbit e ects are large because of the increased coupling between valence and conduction bands associated with strong relativistic e ects. In bulk materials, without magnetic impurities, the only important mechanism producing spin-orbit coupling is the bulk inversion asymmetry [1, 2]. In contrast, in sem iconductor heterostructures, the electron spin-orbit interaction can also be controlled by modication of the subband structure using gate voltages [3], strain [4], or selective doping [5].

The role of spin-orbit except in sem iconductors is gaining a signicant attention because of recent interest in the emerging elds of spintronics and quantum computation [6, 7]. Key issues are the injection and detection of spin-polarized electrons, controlling and manipulating single spins, and the design and experimental realization of novel spintronic devices such as spin-transistors, logic elements, and memory. One obvious way to inject polarized electrons is to use ferrom agnetic contacts [8, 9]. It is also possible to exploit the spin-polarized edge states in lateral quantum dot devices subject to a magnetic ed [10]. A nother, more challenging approach, is to create a spin-polarized current by employing spin-orbit coupling [11]. With the ultimate intention of learning how to manipulate and measure electron spins locally by using gates to modify the spin-orbit interaction, there is a vital interest in searching for semiconductor materials and structures where the electron spin-orbit interaction is large and highly sensitive to gate voltages.

One method which gives information about the spin-orbit coupling is the weak anti-localization (WAL) e ect. This is a quantum interference correction to the conductivity which appears as an abnormal positive magnetoresistance in very low magnetic elds, preceding the more usual negative magnetoresistance associated with weak localization [12]. In metals WAL was thoroughly studied and understood in the 1980's [13]. In semiconductors the situation is more complex because new mechanisms involving spin orbit e ects come into play, such as bulk nonsymmetry, asymmetry at heterointerfaces and in quantum wells, and two-dimensional quantum con nement. [1]

In this work the WAL e ect is used to study spin relaxation due to the spin-orbit interaction in a strained InGaAs/InP quantum well (QW) structure. Compared with an isomorphous (lattice-matched) structure [14], the strained QW structure showed a larger

sensitivity to the gate voltage. In addition an anomalous, non-monotonic, dependence of the spin-orbit time constant on electron concentration was observed. This can not be explained by the conventional bulk inversion and/or Rashba mechanisms and suggests that the existing theoretical understanding of spin orbit elects in transport phenomena in semiconductor structures needs to be improved.

B. Experim ental

The QW structure studied here was grown on a (100) InP sem i-insulated substrate and consisted of the following layers (measured up from the substrate): 450 nm of undoped InP bu er layer, 10 nm In_kG a_{1 x} A s (x=0.76) quantum well, 13 nm undoped InP spacer layer, followed by 13 nm InP doped layer (N_d = 4 10^{3} m 3) and a 13 nm undoped cap layer. The indium content in the quantum well was higher than that of InG aA s lattice-m atched to InP (x=0.53) so the QW was compressively strained.

Standard optical photolithography and wet etching was used to form a $0.2 \,\mathrm{m}\,\mathrm{m}$ wide Hall bar with $0.4 \,\mathrm{m}\,\mathrm{m}$ separation between adjacent potential contacts. A 40 nm $5iO_2$ dielectric layer and a gold gate were deposited on top of this. Measurements were performed in a He3 system; experimental details are given in Ref.14.

Figure 1 shows the electron concentration determ ined from Shubnikov-de H aas oscillations and the Hall mobility (). These transport properties are very similar to those observed earlier in the isom orphous lattice-matched sample studied previously [14]. In particular, the concentration varies linearly with gate voltage while the mobility has a somewhat slower dependence.

The WAL was used to investigate the spin-orbit scattering action to the conductivity appears as a non-monotonic dependence of the magnetoresistance at very low magnetic elds, Bl. An initial positive magnetoresistance is followed by the more usual negative term. In the theoretical description of the interference corrections characteristic values of the conductance and magnetic eld appear, analogous to the Bohr radius and energy in the theory of excitons. It is therefore convenient to plot the conductance (inverse resistance) in units of the quantum conductivity $G_0 = (e^2 = h)$ and the magnetic eld normalized by a characteristic eld B_{tr} given by ~=4eD where $D = v_F^2 = 2 = ~^2 n = m$ e is the direction obth electron

concentration and mobility and therefore has a stronger gate voltage dependence than the density (see insert to Fig.1), changing by more than an order ofm agnitude over the range of V_g used in the experiment. It should be further noted that because it is desirable to eliminate the irrelevant classical Lorentz term in the magnetoconductivity $_{xx}(B) = _{0} = (1 + \ ^{2}B^{2})$ it is also convenient to plot the inverse magnetoresistance $(1 = _{xx}) = 1 = _{xx} \quad 1 = _{0}$ rather than $= _{xx} \quad _{0}$, where $_{0}$ is the zero eld value and $_{0} = 1 = _{0}$. This procedure, which would produce zero in the absence of quantum interference corrections, removes the Lorentz term.

Figure 2 shows experimental traces plotted in this way for dierent gate voltages. The narrow peak around zero magnetice eld is the WAL elect which appears when the spin-orbit scattering rate is comparable to or large than the inverse phase breaking time 1=. It is clear, that in this sample, the WAL elect shows a non-monotonic dependence on gate voltage reaching a maximum around $V_g = -0.3$ and decreasing for both large positive and large negative voltages. Such behavior is unusual and is descussed below.

To extract the phase-breaking and spin-orbit scattering times we attempted to the experiment with the theoretical expression, derived for arbitrary magnetic elds [15]:

(B) =
$$(e^2 = h) \mathbb{F} (x; s_1) + \frac{1}{2} \mathbb{F} (x; s_2) = \frac{1}{2} \mathbb{F} (x; \cdot)$$
 (1)

w here

$$B_{tr} = \frac{\sim}{4eD}; B_{so} = \frac{\sim}{4eD_{so}} \text{ and } B_{r} = \frac{\sim}{4eD_{r}}$$
 (2)

$$x = \frac{B}{B_{tr}} = \frac{4eBD}{\sim};$$
 , = $\frac{}{}$, so = $\frac{}{}$ so; s1 = , + so; s2 = , + 2 so;

with D the di usion coe cient and , $_{\rm so}$ and , respectively the elastic scattering time, the spin-orbit relaxation time and the phase-breaking time. The function F (x; $_{\rm i}$), defined in Refs. 14, 15, describes the interference contributions from the three triplet and one singlet diffusion channels. This equation, derived for an arbitrary magnetic eld, reduces to the well known expression given by Hikami, Larkin and Nagaoka (HLN) [16] in the limit of small magnetic elds B $_{\rm tr}$. For the thing procedure $_{\rm tr}$ is known so there are two adjustable parameters , and $_{\rm so}$ or equivalently (, and $_{\rm so}$). One more remark should be

added here: to fully describe the WALe ect requires a spin-dependent vector potential with a three dimensional character [17, 18, 19]. The two major spin-orbit relaxation mechanisms (D resselhaus and Rashba) are not additive so in general more complicated expressions, with additional thing parameters should be used to describe the experiments. If, however, one mechanism dominates a single scalar parameter $_{\rm so}$ su ces which can then be treated on the same footing as $_{\rm so}$.

The thin solid lines in Fig. 2 are theoretical to using this Eqn. 1. Details of the thing procedure are described in Ref. 14. Although this theory should be valid for arbitrary magnetic elds, it was impossible to obtain a good tover the whole magnetic eld range for any of the data. Fitting the central part (small B) resulted in large deviations at higher elds and vice versa. This is a common problem in semiconductors encountered by many authors, e.g. Ref. 15. A similar large discrepancy between theory and experiment observed in the isomorphous InGaAsQW sample [14] could only be reconciled by introducing an additional, empirical, scale parameter of order two. It was argued there that one reason for the discrepancy might be the fact that the spin orbit scattering time was comparable to the transport relaxation time but this is not the case here: for all the curves shown in Fig. 2

so = so 0:1 satisfying the condition so 1.

Given the large discrepancy between experiment and the theoretical description of the WAL e ect (which appears to be a general property of high mobility 2DEG sem iconductors in high magnetic elds) it is not immediately obvious how to extract values of the spin orbit relaxation time. Further theoretical e ort is needed to x this problem. However, the amplitude of the WAL is clearly a ected by $_{\rm SO}$ and we have chosen to tit using the low eld part of the data where the turnover from a negative to a positive magnetoconductivity is sensitively dependent on $_{\rm SO}$. This approach has the advantage that it is also consistent with the procedure commonly used in the literature whereby the low—eld peak is tted to the HLN expression [5, 16, 19, 20, 21] with the implicit understanding that deviations at higher elds are to be expected because of inadequacies in the theory.

The tted theoretical curves shown on Fig. 2 are plotted well beyond the range of the to emphasize the unexpected discrepancy between theory and experiment and to stimulate the attention of theorists.

C. Discussion

Although the appearance of the WAL elect requires strong spin orbit scattering, the curvature of the WAL peak at B=0 and the characteristic width are in fact not determined by so but rather by the phase breaking time \cdot [14, 22]. It is the amplitude of the WAL, in particular the crossover from WAL to weak localizing behavior, that is determined by the ratio $\cdot = 0$.

From Fig. 2 it can seen that the central part of the WAL peak at B=0 changes little for dierent V_g and indeed, all the ts gave the same value for parameter \cdot = 0.010 0.001 (for curve at V_g = +0.1, where the WAL had vanished, \cdot was set to 0.010 and only so tted). The WAL peak is narrow because its width is determined not by so but rather by \cdot which can be very small in high mobility samples. Without spin-orbit scattering a weak localization peak would appear with the same width but of opposite sign.

The phase breaking time extracted from the ts to the data is plotted in Fig. 3 compared with the predictions of electron-electron scattering calculated from a Fermi liquid model [12, 23]:

$$\frac{1}{r} = \frac{k_B T}{r} \frac{G_0}{r} \ln \frac{0}{2 G_0}$$
 (3)

with $G_0 = e^2 = (h)$, and $k_BT = 1$. The experimental values of , shown in Fig.3 are all smaller than predicted. In the literature an empirical coexient of order 2 is often introduced to bring the experimental data into better agreement with Eq. 3 [24, 25] but the discrepancy is larger than this. While this model generally works well in metals, where Fermienergy is large and the electron gas can be considered as being very uniform [12, 13] deviations appear at low temperatures, and a fortior in semiconductors. The phase breaking time is almost universally observed to saturate as the temperature is lowered. For all the data shown in Fig.3 the temperature was su ciently low that this saturation had occurred. That is, the absence of any signicant gate voltage dependence in , rejects the temperature saturation rather than an intrinsic insensitivity to electron concentration. The saturation in plies that there exist additional phase-breaking mechanisms, the analysis of which is not the topic of this paper.

Figure 4 shows the spin-orbit scattering rate determined from the $\,$ ts to the data in Fig. 2. It is evident that $\,$ so is a non-m onotonic function of the electron concentration. In 2D EG

systems the two major spin-orbit scattering mechanisms identied in the literature are the D resselhaus term, associated with the bulk zinc-blend crystal inversion asymmetry, and the Rashba term associated with built-in electricelds [26]. To identify which mechanism dominates here it is helpful to consider the dependence on electron concentration of B $_{\rm so}$ = \sim =(4eD $_{\rm so}$) [20, 21, 26]. This value, deduced from the data in Fig.4a and the transport parameters shown in Fig.1, is plotted in Fig.4b.

When the Dresselhaus mechanism dominates B_{so} should increase with increasing density [20] but in samples where the large spin-orbit coupling is large, such as that considered here, the Rashba term usually dominates. The Rashba term results from structural asymmetry and is proportional to the internal electric eld. Because the eld is proportional to the surface charge density it should therefore increase as the concentration in the quantum well increases (see e.g. Ref. 3). In general, the Rashba e ect may therfore lead to a nonmonotonic dependence of spin-orbit splitting on gate voltage with a minimum corresponding to a sym m etric quantum well. [27] In our case, however we observe a maximum of the spin orbit scattering rate (Fig. 4). To our best know ledge this is the rst report of such behavior. A non-m onotonic dependence of $_{50}$ on electron concentration in Fig. 4 cannot be explained by either the D resselhaus or the Rashbam echanisms and some extra e ect, such as strain or the role of the interfaces must be involved. In the literature the role of interfaces in the Rashba m echanism is som ew hat controversial. Within the elective mass approximation the expectation value of a (sm ooth) potential gradient integrated over all space is always zero [18, 28]. M ore generally, the contribution from each separate interface is as large (or even larger) as that from the quantum wellasymmetry [28, 29]. The two interfaces in a quantum welloften have di erent properties resulting , for exam ple, from the growth process. As a result changes in the amplitude of the electron wavefunction at each interface, produced by changes in gate voltage, will be re ected by changes in any asymmetry associated with having two dierent interfaces. The unexpected experimental observation that so is a non-monotonic function of gate voltage shows such an e ect plays an important role here.

An alternative method of investigating the strength of the spin-orbit coupling is to use inform ation from the beat patterns of the low eld Shubnikov-de H aas (SdH) oscillations [29, 30, 31, 32]. There has, to our know ledge, been no published comparison of results obtained in this way with those deduced, in the same sample, from the WALe ect. In Ref. 27 the authors observed beats in SdH oscillations and an anomalous positive magnetoresistance

at low eld which could be due to WALe ect. However, in a more detailed study the authors [33] suggested the situation is more complex with the observed positive magnetoresistance being due to combination of several factors including the presence of two spin subbands, a corrugated quantum well, mobility anisotropy, and "possibly weak anti-localization". In the sample studied here, and also in the isomorphic sample studied previously [14] that had a much larger spin-orbit scattering rate, a careful exam ination of the Shubnikov-de Haas oscillations, over a wide range of gate voltages, revealed no sign of any beats. In other samples, under conditions when there was some parallel conduction, beats could sometimes be seen similar to those observed by other authors. However, when analyzed in detail by making gray-scale plots using many traces with small steps in gate voltage, the systematic behavior expected from spin orbit splitting could not be confirmed. In our samples we identify the beat pattern observed with interference between two sets of two SdH frequencies, originating from the gated and ungated parts of the sample, and coupled through the parasitic parallel conduction. A similar observation has been made by Ensslin et al. [34] when they also failed to not any beats in a high quality InAs/Alsb quantum well sample.

D. Conclusions

Spin-orbit relaxation in a strained InG aA s/InP QW structure was studied using the WAL e ect. The spin-orbit relaxation time was found to depend strongly, and non-monotonically, on the gate voltage with the maximum scattering rate ($1=_{so}=5$ $10^{0}\,\mathrm{sec}^{\,1}$) reached at a density of n=3 $10^{5}\,\mathrm{m}^{\,2}$. This behavior cannot be explained by either the Rashba or bulk D resselhaus mechanisms but is rather attributed to asymmetry or strain elects at dissimilar QW interfaces.

Compared with a similar, but unstrained sample, the spin-orbit scattering rate here is smaller (by a factor of over 100 at the highest densities). In the strained sample $_{\rm so}$ shows a strong gate voltage dependence (varying from 20 to 1000ps) while in the unstrained sample $_{\rm so}$ was only weakly dependent on electron concentration. This demonstrates that strain can be used as a tool for producing desirable spin-orbit properties when engineering materials for spintronics applications. The exact mechanism responsible for the variation of the spin-orbit coupling in strained samples is not yet understood and is the subject of further investigations. Further theoretical work is also needed to explain correctly the

experim entally observed magnetic eld dependence, particularly in samples where the WAL e ect is large.

E. A cknow ledgem ents

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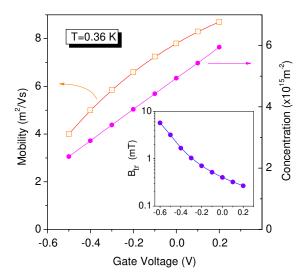


FIG. 1: E lectron concentration (solid circles) determ ined from Shubnikov-de H aas oscillations and the H allm obility (open squares) of the InG aA s/InP QW structure. Insert shows the characteristic magnetic eld B $_{\rm tr}$ = ~=4eD as a function of the gate voltage.

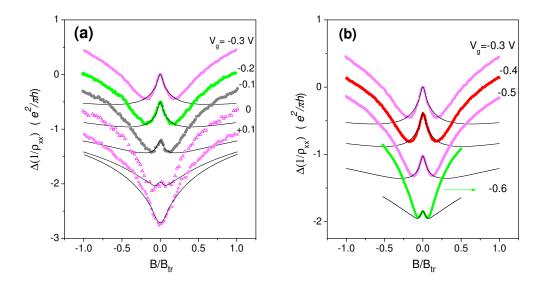


FIG.2: Experim ental traces of the magnetoresistance for dierent gate voltages at $T=0.36~\mathrm{K}$.

- (a) $V_g = 0.1, 0, -0.1, -0.2$, and -0.3 V;
- (b) $V_g = -0.3$, -0.4, -0.5, and -0.6 V.

Thin solid lines are best theoretical ts to the experim ent using Eq.1.

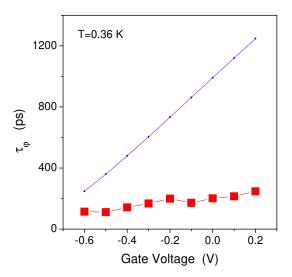


FIG. 3: Phase breaking time obtained from set of the data in Fig. 2 as a function of the gate voltage. Straight line is the theoretical limit due to the electron-electron scattering.

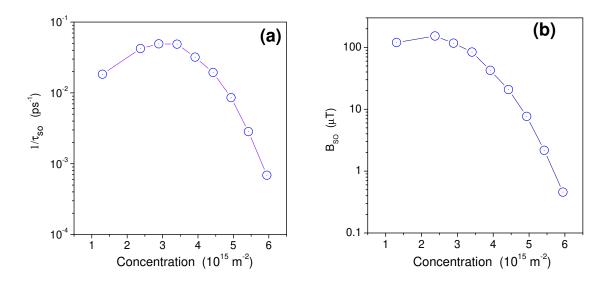


FIG. 4: (a) Spin-orbit scattering rate determined from data in Fig. 2 as a function of electron concentration.

(b) Spin-orbit m agnetic eld parameter B $_{so}$ = ~=(4eD $_{so}$) as a function of electron concentration calculated on the basis of Figs. 1 and 4(a).